

# Intensity Noise and Pulse Oscillations of an InAs/GaAs Quantum Dot Laser on Germanium

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**Abstract**—This paper investigates the intensity noise and pulse oscillation characteristics of an InAs/GaAs quantum dot laser epitaxially grown on germanium. We show that the relative intensity noise of the free-running laser generally decreases with increasing pump current, and the minimum value reaches down to about  $-126$  dB/Hz. The intensity noise is hardly affected by the optical feedback, unless there is a resonance or pulse oscillation in the noise spectrum. The laser pumped at a high current is more sensitive to the optical feedback. Interestingly, it is found that the free-running Ge-based quantum dot laser generates self-sustained pulse oscillations with one period or two periods upon the pump current, without incorporating saturable absorbers. This behavior is valuable for both self-generation of photonic microwaves and for understanding nonlinear dynamics of semiconductor lasers.

**Index Terms**—Quantum dot laser, silicon photonics, intensity noise, optical feedback, Q switching, nonlinear dynamics.

## I. INTRODUCTION

PHOTONIC integrated circuits (PICs) on silicon (Si) are developing rapidly since 2000s, owing to the large transmission bandwidth requirement in data centers, and the fast calculation speed requirement in neural networks [1]–[3]. Various optical components including optical modulators, waveguides, photodiodes, and optical switches have been successfully

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demonstrated on the silicon platform [4]–[6]. Nevertheless, it is still very challenging to integrate reliable semiconductor lasers on Si, because Si is inefficient for achieving stimulated emission due to its indirect bandgap structure [7], [8]. One of the most successful solutions to circumvent this problem is to integrate mature III-V semiconductor lasers on Si, thanks to the superior optical properties of III-V materials [7]. The common three integration techniques include flip-chip bonding, wafer bonding, and direct epitaxial growth [9]–[12]. In comparison with the former two methods, the latter one has a much higher potential to achieve low-cost, high-yield, and large-scale production [8]. However, the large lattice mismatch between III-V materials and Si (4% for GaAs and 8% for InP) leads to high-density threading dislocation defects, which increases the lasing threshold and reduces the aging lifetime [9], [13]. Despite that, thanks to the low sensitivity of nanostructures to epitaxial defects, both InAs/GaAs and InAs/InP quantum dot (QD) lasers have been successfully grown on Si since 2010s [8], [14]–[16]. On the other hand, taking advantage of the mature Ge-Si wafer technology, InAs/GaAs QD lasers can also be conveniently grown on germanium (Ge), owing to the small lattice mismatch between GaAs and Ge (only 0.08%) [9], [17]. In addition, Ge-based photodiodes, optical modulators and waveguides exhibit superior performances and high potential of compatibility with CMOS circuits, making the development of Ge-based QD lasers attractive as well [18]–[20].

In recent years, tremendous efforts have been devoted to improve the quality of InAs/GaAs QD lasers epitaxially grown on Si [8], [13], [21], [22]. Consequently, Ge- and Si-based QD lasers have demonstrated comparable static performances with QD lasers on native GaAs substrate, including low threshold current density [21], high temperature stability [14], and long aging lifetime [23]. In terms of dynamical performances, the relative intensity noise (RIN) and its sensitivity to optical feedback have drawn a lot of attentions, in particular because the RIN directly affects the bit error rate in the data transmission [24], [25]. On the other hand, residual optical feedback in the optical link can significantly raise the RIN level once the feedback strength exceeds the critical feedback level, which drives the laser into coherence collapse and severe chaotic oscillations [26], [27]. Consequently, an optical isolator is usually accompanied with semiconductor lasers to avoid any residual optical feedback in optical transmission systems. A. Liu *et al.* reported that a Si-based QD laser had a 20-dB reduced sensitivity to optical feedback than a quantum well laser [28]. Y. G. Zhou *et al.*

found that the RIN of a Ge-based QD laser was 15-dB higher than a GaAs-based one, due to the high density defects [17]. On the other hand, both Ge- and Si-based lasers are also found less sensitive to the optical feedback, because the defects contribute to increasing the damping factor, which is helpful to enhance the critical feedback level [29], [30]. H. Huang *et al.* also showed that a large threshold difference between the excited state and the ground state was beneficial to enhance the optical feedback tolerance of a Si-based QD laser [30]. Besides, M. Liao *et al.* demonstrated a Si-based QD laser with a RIN of about -150 dB/Hz [31]. In addition to the large damping factor, a low linewidth broadening factor (LBF) is also helpful to reduce the phase amplitude coupling and hence the optical feedback sensitivity [32]. Recently, J. Duan *et al.* reported Si-based QD lasers with ultra-low LBFs in the range of 0.1-0.5, thanks to the improved high uniformity of QD sizes [33]. In addition, it was demonstrated that the p-doping could further reduce the LBF. For the direct modulation of Si-based QD lasers, D. Inoue *et al.* reported a 3-dB bandwidth of 6.5 GHz associated with a 12.5 Gbps non-return-zero large signal modulation [22]. Besides, C. Hantschmann *et al.* analyzed the modulation properties of a Si-based QD laser with a small-signal bandwidth of 1.6 GHz [34]. Very recently, S. Liu *et al.* demonstrated both single-section and two-section mode-locked QD lasers on Si, respectively [35], [36].

The aim of this work has two folds: on one hand, we investigate the intensity noise and its optical feedback characteristics of an InAs/GaAs QD laser epitaxially grown on Ge. On the other hand, we unveil the self-sustained pulse oscillations of the free-running Ge-based laser. The laser exhibits a LBF of 2.5 at the gain peak. Increasing the pump currents reduces the RIN down to -126 dB/Hz, while the optical feedback does not significantly raise the RIN for feedback levels up to 7.0%, with a round-trip optical feedback length of 42.8 m. Interestingly, the free-running Ge-based QD laser exhibits self-sustained pulse oscillations with one period or two periods, depending on the pump currents. Among these, the period-one oscillation is useful for photonic microwave generation and hence is analyzed in details. The paper is organized as follows: Section II describes the epi-layer structure of the Ge-based QD laser and its static properties. Section III discusses the RIN and its optical feedback sensitivity. Section IV investigates the self-sustained pulse oscillation characteristics, and Section V summarizes this work.

## II. LASER STRUCTURE AND STATIC PROPERTIES

Fig. 1 shows the epi-layer structure of the InAs/GaAs QD laser epitaxially grown on Ge. A 600-nm thickness GaAs buffer layer was first grown on the Ge substrate with  $6^\circ$  off-cut towards [111] plane by the gas-source molecular beam epitaxy. The GaAs buffer layer restrains the propagation of epitaxial defects including anti-phase boundaries and threading dislocations into the active region. The defect density on the buffer layer surface is estimated to be around  $10^6 \text{ cm}^{-2}$ , by counting the number of rhombic pinholes in the atomic force microscopy image. The active region consists of 5 stacked dot-in-well (DWELL) layers, and each layer is composed of 2.2 monolayer (ML) InAs

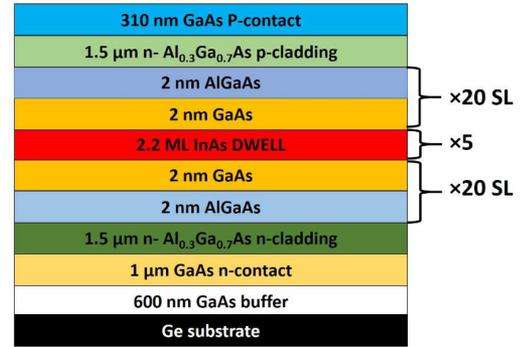


Fig. 1. Epi-layer structure of the InAs/GaAs QD laser on Ge substrate.

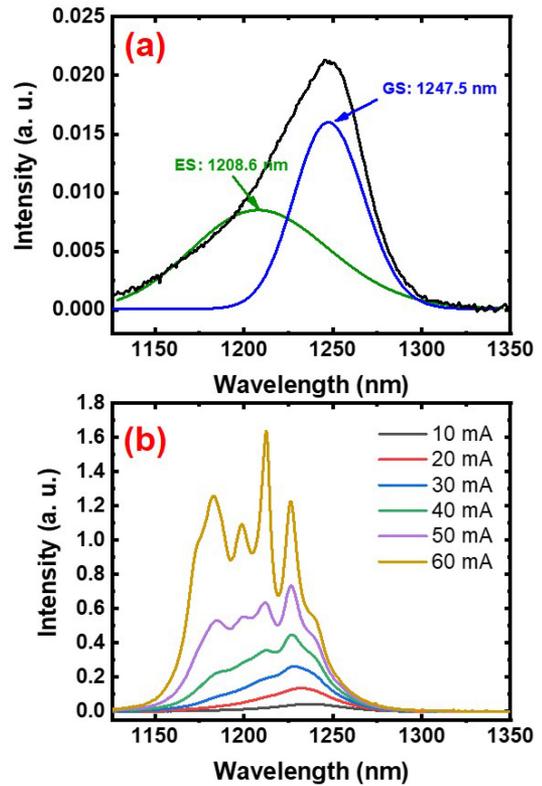


Fig. 2. (a) PL spectrum and (b) EL spectra of the Ge-based QD laser.

QDs. The dot density is about  $2.0 \times 10^{10} \text{ cm}^{-2}$ , with an average dot diameter of 61 nm and an average height of 10 nm. The laser was fabricated into ridge waveguide with a ridge width of  $4.0 \mu\text{m}$ , and a cavity length of 4.4 mm. Both laser facets are left as-cleaved without any coatings [29]. Fig. 2(a) shows the photoluminescence (PL) spectrum of the Ge-based QD wafer measured at  $20^\circ\text{C}$ , which shows a linewidth (full width at half maximum) of 60 nm (48 meV). The Gaussian fitting of the PL spectrum shows that the ground state (GS) peaks around 1247.5 nm, and the first excited state (ES) locates 39 nm away (32 meV). The large inhomogeneous broadening of dot size leads to the wide energy overlap between the ES and the GS. Fig. 2(b) shows the electroluminescence (EL) spectra of the laser

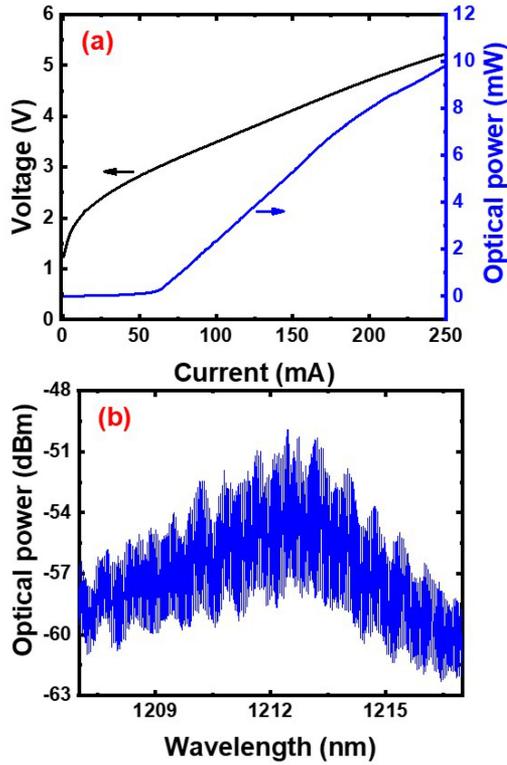


Fig. 3. (a) L-I-V curve of the Ge-based QD laser. (b) Optical spectrum at the lasing threshold.

operated below the lasing threshold. Close to the threshold, the laser exhibits four distinct peaks around 1182 nm, 1200 nm, 1212 nm and 1226 nm, respectively. All the energy separations between adjacent peaks are less than 15 meV, which is much less than the GS and the ES separation. Therefore, the generation of multiple peaks is not due to the localized states. It might be because of that there are multiple groups of dots, which populate independently [37]. However, it is unclear why the homogeneous broadening does not group the dots into one ensemble [38]. Therefore, the corresponding physical mechanism still requires further exploration.

Throughout the measurements in this work, the laser operation temperature is maintained at 20 °C by a thermo-electric cooler. Fig. 3(a) shows that the Ge-based QD laser exhibits a lasing threshold of  $I_{th} = 60$  mA, associated with a threshold voltage of 3.0 V. The series resistance determined by the V-I curve is 12.1  $\Omega$ . The optical spectrum at the lasing threshold in Fig. 3(b) centers around 1213 nm. The longitudinal mode spacing is 0.43 nm, resulting in a group refractive index of 3.84 and a facet power reflectivity of 0.34. Based on the Hakki-Paoli method [39], [40], Fig. 3(a) extracts the net modal gains at sub-threshold currents using the optical spectra of amplified spontaneous emission. The gain spectra are asymmetric due to the dot size dispersion, which leads to the non-zero LBF in Fig. 4(b). In the measurement of the sub-threshold LBF, the carrier-induced blue shift of the optical wavelength is extracted by carefully removing the thermal effect, which is determined by the above-threshold red-shift of the wavelength [41]. Fig. 4(b) shows that

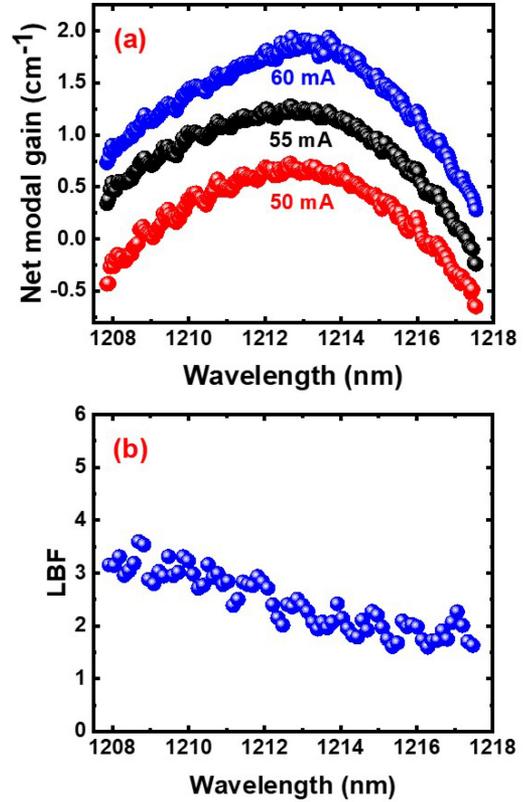


Fig. 4. (a) Net modal gain for several sub-threshold pump currents. (b) LBF of the Ge-based laser versus the lasing wavelength.

the LBF displays a relatively large sub-threshold value, which varies from about 3.0 at 1208 nm down to about 2.0 at 1218 nm, and the LBF value is 2.5 at the gain peak (1213 nm). The decreasing LBF as a function of the wavelength can be attributed to the inhomogeneous broadening of the gain medium deviating from Gaussian lineshape, as well as the carrier contribution in the higher energy states of QDs [42]. It is noted that the LBF of QD lasers operated above threshold is larger than that below threshold, and usually increases with the pump current [43], [44]. This may contribute to the rich nonlinear dynamics discussed in Section IV.

### III. INTENSITY NOISE AND SENSITIVITY TO OPTICAL FEEDBACK

This section first investigates the RIN of the free-running InAs/GaAs QD lasers on Ge, and then discusses its sensitivity to optical feedback.

#### A. Relative Intensity Noise

The RIN of the Ge-based QD laser is measured through converting the optical signal into electrical one using a fast photodiode with a bandwidth of 10 GHz. The electrical spectrum of the intensity noise is measured on a broadband electrical spectrum analyzer (Rohde&Schwarz FSU43), and the DC electrical power is tracked on a multimeter [17]. Fig. 5(a) shows the

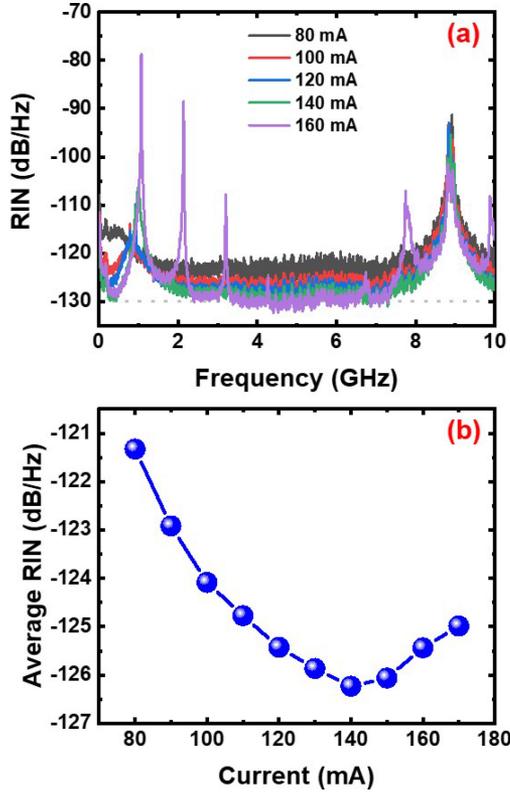


Fig. 5. (a) RIN spectra of the Ge-based QD laser at several pump currents. (b) Averaged RIN values within 10 GHz as a function of the pump current.

measured RIN spectra of the Ge-based laser at several pump currents. At 80 mA, the laser exhibits a clear relaxation oscillation resonance at 0.4 GHz, where the RIN is amplified. In the frequency range of 2.0–7.0 GHz, the RIN becomes almost constant. Interestingly, a broad peak appears at 8.9 GHz, corresponding to the free spectral range of the Fabry-Perot laser. This phenomenon is recognized as the photon-photon resonance (PPR), which originates from the quasi-phase locking of multiple longitudinal modes [45]–[47]. The quasi-phase locking mechanism is usually provided by gratings including distributed feedback and Bragg reflector [48], [49]. The PPR has been widely explored to enhance the modulation bandwidth of semiconductor lasers, in combination with the relaxation oscillation resonance [50], [51]. However, it is not common to observe the PPR in a Fabry-Perot cavity. The quasi-phasing locking mechanism in this laser can be attributed to high third-order nonlinear susceptibility of QDs, which leads to strong four-wave mixing effect [52]–[54]. The high third-order susceptibility has been proved to be responsible for the self mode-locking commonly observed in single-section QD lasers [35], [55]–[57]. Unlike grating lasers, the PPR frequency of the tested Fabry-Perot laser does not increase with the pump current, because cavity length does not change. On the other hand, increasing current enhances the relaxation oscillation frequency. However, the resonance peak becomes sharper and higher instead of being overdamped. Finally, the resonance peak evolves into pulse oscillations, which

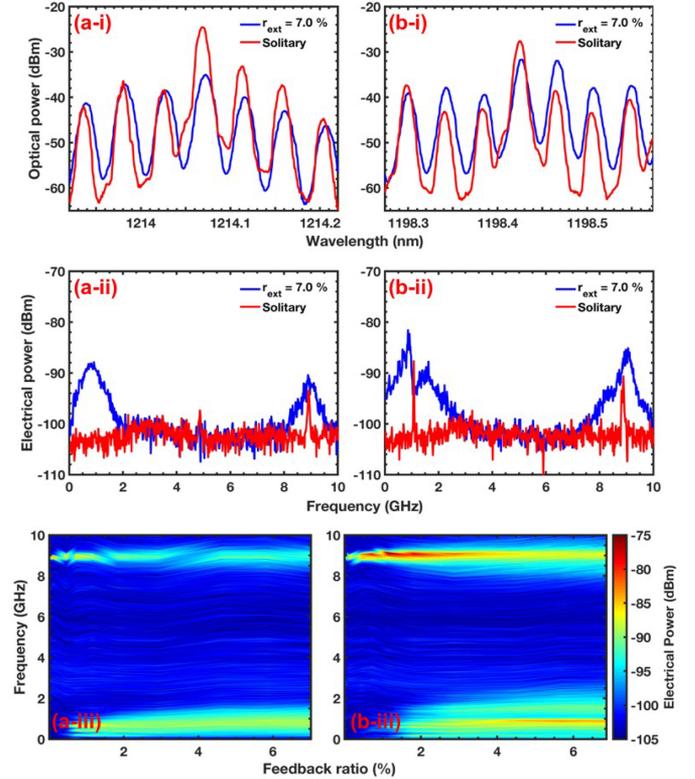


Fig. 6. Optical feedback dynamics of the Ge-based QD laser at (a)  $1.5 \times I_{th}$  and at (b)  $2.5 \times I_{th}$ , respectively. The first row is the optical spectrum and the second one is the electrical spectrum, with ( $r_{ext} = 7.0\%$ ) and without optical feedback. The third row is the electrical power distribution map formed by the feedback ratio and the microwave frequency.

will be discussed in details in Section IV. The RIN value averaged over 10 GHz in Fig. 5(b) reduces with the pump current from  $-121.3$  dB/Hz at 80 mA down to the minimum level of  $-126.2$  dB/Hz at 140 mA. Above 140 mA, the averaged RIN re-increases due to the appearance of multiple peaks shown in Fig. 5(a).

### B. Sensitivity to External Optical Feedback

In order to investigate the external optical feedback sensitivity of the Ge-based laser, we employ a commercial back-reflector (EXFO BKR) to provide optical feedback with a tunable feedback ratio  $r_{ext}$  up to 7.0% [30]. The round-trip optical feedback length is fixed at 42.8 m. Fig. 6 presents the optical feedback characteristics of the Ge-based laser pumped at  $1.5 \times I_{th}$  (Fig. 6(a)) and  $2.5 \times I_{th}$  (Fig. 6(b)), respectively. At a feedback ratio of about 7.0%, the amplitudes of some longitudinal modes are raised while the others are suppressed, due to the interaction with external cavity modes [58], [59]. At a feedback ratio of about 7.0%, the spectral linewidth of the laser does not show any significant broadening, indicating no clear transition towards the chaotic regime (e.g., coherence collapse). The electrical spectra in Fig. 6(a-ii) and Fig. 6(b-ii) prove that the optical feedback raises the intensity noise both around the oscillation resonance (1.0 GHz) and around the PPR (8.9 GHz). On the other hand,

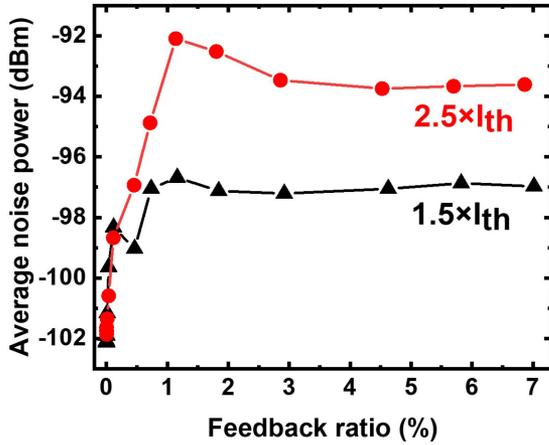


Fig. 7. Averaged intensity noise power within 10 GHz as a function of feedback ratio at  $1.5 \times I_{th}$  and  $2.5 \times I_{th}$ , respectively.

optical feedback has little impact on the flat part of the intensity noise. The electrical power distributions in Fig. 6(a-iii) and Fig. 6(b-iii) show that both the relaxation oscillation peak and the PPR peak are broadened significantly at  $2.5 \times I_{th}$  than at  $1.5 \times I_{th}$ , although the optical spectra are not broadened. Therefore, it is hard to exclude the presence of chaotic oscillations under this feedback condition [27], [60]–[63]. Fig. 7 shows that the average intensity noise within 10 GHz is significantly raised by the weak optical feedback up to 1.0%: from  $-102.1$  dBm to  $-96.7$  dBm at  $1.5 \times I_{th}$ , and from  $-101.8$  dBm to  $-92.1$  dBm at  $2.5 \times I_{th}$ . Interestingly, the intensity noise for both currents becomes relatively insensitive to the optical feedback with feedback ratio above 1.0%. The measured noise powers at  $2.0 \times I_{th}$  and at  $3.0 \times I_{th}$  exhibit similar behavior as well. Obviously, the Ge-based laser is more sensitive to the optical feedback at higher pump currents, as usually observed in multimode QD lasers [29], [32], [62], [64]. This can be attributed to the larger LBF, the heavier thermal effect, as well as increased number of lasing modes [27], [44], [65]. It is worthwhile to mention that the intensity noise in Fig. 7 does not show a kink, above which the feedback significantly raises the noise level [66].

#### IV. SELF-SUSTAINED PULSE OSCILLATIONS

QD lasers incorporating a saturable absorber can generate pulse oscillations, owing to the passive Q-switching mechanism [67]–[69]. Because the carrier lifetime of QDs is in the nanosecond range, the resulted pulsation frequency is usually around 1.0 GHz range. Particularly, Viktorov *et al.* observed a period doubling sequence of bifurcations to chaos in a two-state QD laser with a saturable absorber [70]. Interestingly, a QD laser without an absorber section was observed to show self-sustained pulsations [71]. The pulse generation was attributed to the large overlap between the GS and the ES of QDs, where unsaturated GS provided saturable absorption for the laser emission from the ES.

Fig. 5(a) has shown that the relaxation resonance peak of the free-running laser became less damped at a higher pump current,

and evolved into self-sustained pulse oscillation at 140 mA and 160 mA. The phenomenon is analogous to the laser dynamics in the vicinity of Hopf bifurcation when the laser is subject to optical injection or optical feedback, although the corresponding mechanisms are different [27], [72]. In the range of 140–190 mA, the free-running QD laser exhibits pulse oscillations with one period in the time domain. As an example, the laser pumped at 170 mA in Fig. 8(a) shows a fundamental oscillation frequency at  $f_0 = 1.09$  GHz on the electrical spectrum (left column). The corresponding time series (middle column) and the phase portrait (right column) clearly show the feature of period-one oscillation. Increasing the pump current enhances the amplitude of the microwave peak. When the laser is pumped in the range of 190–200 mA (see 196 mA in Fig. 8(b)), a sub-harmonic peak appears at half of the fundamental frequency in the electrical spectrum. Meanwhile, the time series exhibits two periods and the corresponding phase portrait shows two cycles, verifying the period-two oscillation. Further increase of the pump current to the range of 200–220 mA (see 210 mA in Fig. 8(c)) slightly enhances the fundamental frequency ( $f_0 = 1.11$  GHz at 210 mA). In addition, the amplitude of the sub-harmonic peak in the electrical spectrum is raised as well. The electrical spectrum in Fig. 8(c) has no qualitative difference with Fig. 8(b), which can be continuously and smoothly transformed to each other. Thus, Fig. 8(c) is period-two oscillation as well. However, the corresponding time series and the phase portrait are deformed, where two loops about the center of the orbit are required to complete one period. When the laser is operated in 220–230 mA, the fundamental frequency slightly decreases, and the amplitude of the sub-harmonic peak reduces as well. Further increasing the pump current to the range of 230–250 mA (see 240 mA in Fig. 8(d)), the laser undergoes an inverse period-doubling bifurcation back to period-one oscillation as shown in the electrical spectrum. The fundamental frequency slightly increases with increasing pump current ( $f_0 = 1.25$  GHz at 240 mA). On the other hand, both the time series and the phase portrait are strongly deformed.

It is found that the evolution of the self-sustained pulse oscillations of the Ge-based QD laser in Fig. 8 is closely related to the variation of the optical spectra in Fig. 9. The optical spectra in Fig. 9(a) show multiple peaks, as suggested in the EL spectra in Fig. 2(b). When the laser is operated in the continuous-wave range (60–140 mA), the two peaks with shorter wavelengths  $P_{1,2}$  are far below the lasing threshold, while the three peaks with longer wavelengths  $P_{3,4,5}$  are above threshold and hence emit photons. When the laser is operated in the pulse oscillation range (140–250 mA), the peaks  $P_{3,4,5}$  have little power variation, and hence the generation of pulse oscillations is less likely related to these three peaks. On the other hand, the main change of the optical spectrum in this range is that the peak  $P_1$  becomes lasing. Therefore, we believe the pulse oscillation dynamics is governed (at least partially) by the evolution of the peak  $P_1$ . The generation of  $P_1$  might be due to the carrier population in a separate group of dots, like the generation of other peaks. Another possible reason is that  $P_1$  emission comes from the carrier population in the ES, because the separation (43 nm) between  $P_1$  and  $P_5$  is similar to the ES and GS separation (39 nm) in the PL spectrum in Fig. 2(a). In addition, we believe the peak

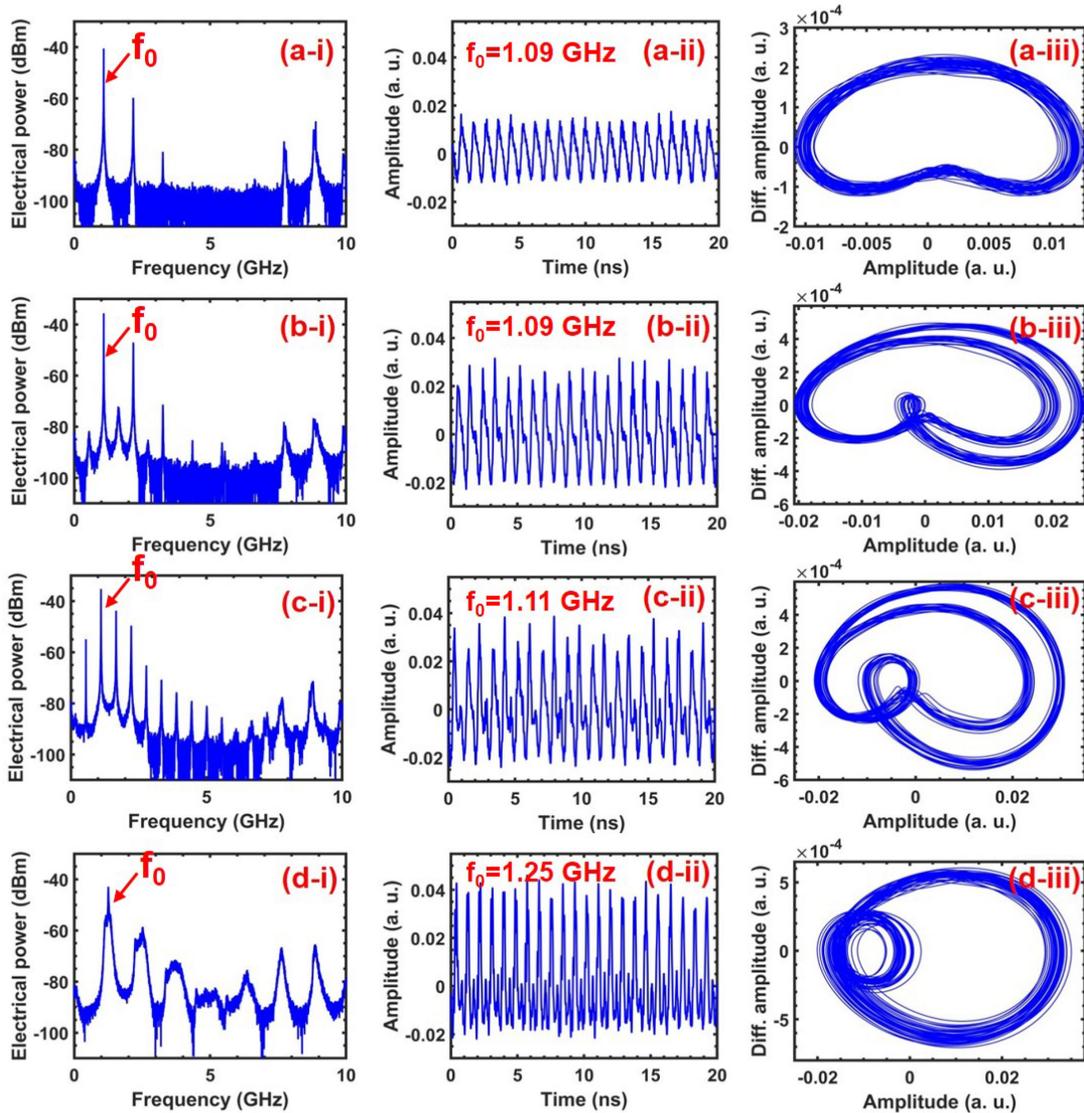


Fig. 8. Electrical spectra (left), time series (middle), and phase portraits (right) of the free-running Ge-based laser at (a) 170 mA, (b) 196 mA, (c) 210 mA, and (d) 240 mA.

$P_2$  plays a crucial role in the pulsation dynamics as well, which remains below threshold in the whole current range. Therefore, the states governing  $P_2$  are only partially populated, and hence unsaturated. The separation between  $P_1$  and  $P_2$  is only 10 nm (9.0 meV). Thus, it is not surprising that the states governing  $P_1$  have some overlap with those governing  $P_2$ , due to the large inhomogeneous broadening (see Fig. 2). Consequently, the unsaturated states of  $P_2$  can provide saturable absorption for the overlapped states of  $P_1$  once it becomes lasing. It suggests that the Q-switch mechanism is responsible for the pulsation dynamics observed in Fig. 8. The time-varying loss level induced by the unsaturated states of  $P_2$  is dependent on both the pump current and the emitted photon density from  $P_1$  [73]. The Q-switching mechanism is similar to the pulsation reported in [71], where the unoccupied GS acts as a saturable absorber for the QD laser emission from the ES. However, that laser does not show period-two oscillations.

When the Ge-based laser is operated in the regime of 140–190 mA,  $P_1$  is only slightly above the lasing threshold and emits a weak optical power, leading to the generation of period-one oscillation. Increasing the pump current enhances the optical power of  $P_1$ , and hence increases the microwave power in Fig. 8(a). The optical power of  $P_1$  keeps increasing in the regime of 190–230 mA, resulting in period-two oscillation. When the laser is operated above 230 mA, the optical power of  $P_1$  becomes weak, driving the laser back to period-one oscillation. It is remarked that another tested laser with a cavity length of 2.2 mm exhibits similar pulsation behavior, which shows multiple peaks in the optical spectrum as well. However, not all Ge-based QD lasers produce self-sustained pulsations, depending on the structure of the optical spectrum.

The period-one pulse oscillation at 140–190 mA in Fig. 8(a) can be used for the generation of photonic microwaves [74]–[77]. Fig. 10(a) shows the frequency and the power of the

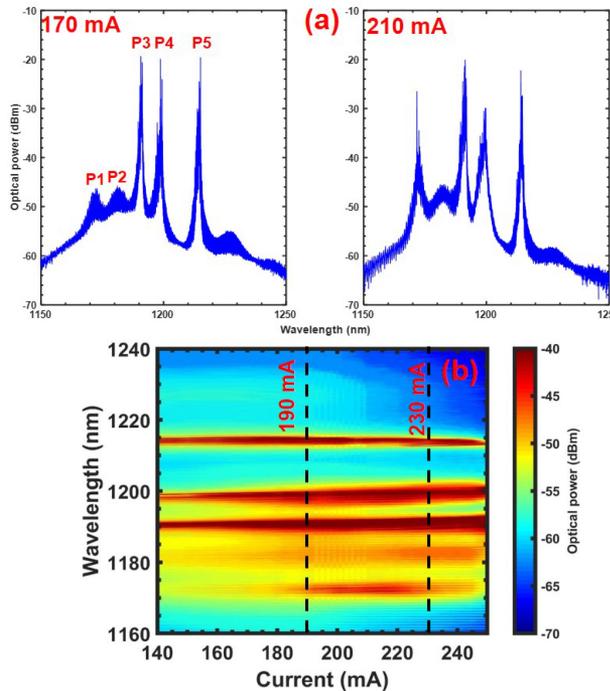


Fig. 9. (a) Optical spectra at 170 mA (left) and 210 mA (right). (b) Optical power distribution map versus pump currents. Dashed lines indicate pump currents of 190 mA and 230 mA, respectively.

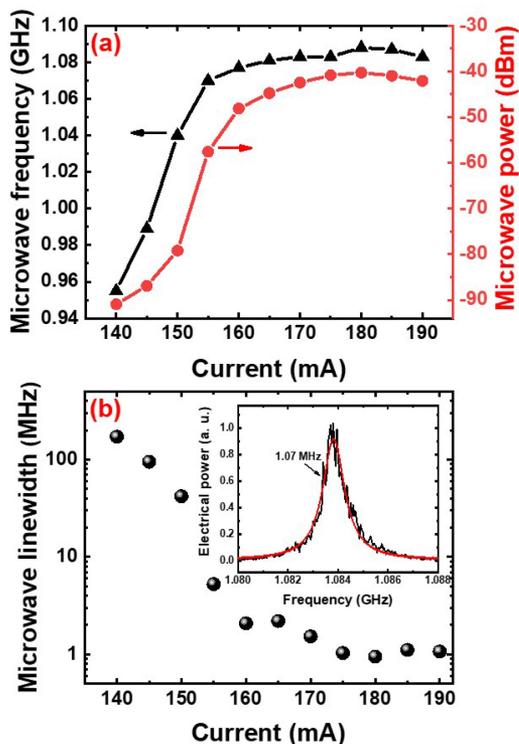


Fig. 10. Photonic microwave generated by the period-one pulse oscillation. (a) Microwave frequency and power. (b) Microwave linewidth as a function of the pump currents. The inset in (b) shows the lineshape of the microwave at 190 mA.

generated microwave as a function of the pump currents. It is shown that the microwave frequency slightly increases from 0.96 GHz at 140 mA to 1.08 GHz at 170 mA. Meanwhile, the microwave power significantly goes up from  $-91$  dBm to  $-42$  dBm. At above 170 mA, both the microwave frequency and the microwave power only vary slightly. On the other hand, the microwave linewidth in Fig. 10(b) decreases with the pump currents from 171.6 MHz at 140 mA down to 1.5 MHz at 170 mA. The decreasing microwave linewidth can be (partly) attributed to the reduction of laser phase noise with increasing pump current. Similar to the frequency and power, the linewidth also has little variation above 170 mA, which saturates around 1.0 MHz (see inset of Fig. 10(b)). It is remarked that the PPR peak at 8.9 GHz may distort the quality of the microwave signal generated by the period-one oscillations. This problem can be circumvented by employing a microwave filter to purify the microwave.

## V. CONCLUSION

In summary, we investigate the dynamical characteristics of the intensity noise and the self-sustained pulse oscillations of an InAs/GaAs QD laser epitaxially grown on Ge. The laser shows a sub-threshold LBF of 2.5 at the gain peak. The minimum RIN of the laser is around  $-126$  dB/Hz. When the laser is subject to optical feedback, the intensity noise is hardly affected except at the resonance or pulse oscillation peak. We also demonstrate that the laser pumped at high currents is more sensitive to the optical feedback. In addition, we unveil that the free-running Ge-based QD laser exhibits self-sustained pulse oscillations, emerging from the undamped relaxation oscillations. The pulse oscillations exhibit one period or two periods, depending on the pump currents. The generation of the self-sustained pulse oscillation is qualitatively attributed to the Q-switching mechanism. Finally, we show that both the microwave power and frequency produced by the period-one oscillation increase with the pump currents, while the microwave linewidth is reduced down to about 1.0 MHz. Future work will theoretically investigate the self-sustained pulse oscillation behavior through numerical simulations, which can offer an in-depth insight on the corresponding physical mechanisms.

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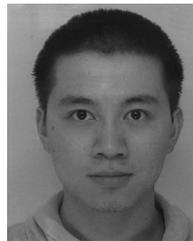
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